

Receipt #6

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Date 4/25/02 Sig: Marjorie Scariati  
Name: Marjorie Scariati

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

APPLICANT(S): David S. Mui et al.

SERIAL NO.: 09/905,172

FILING DATE: 07/13/2001

TITLE: ETCH PATTERN DEFINITION USING A CVD LAYER AS AN ANTI-REFLECTION COATING AND HARDMASK

ART UNIT: 1765

DOCKET: 004227USA02/ETCH/SILICON/JB1

U.S. Patent and Trademark Office  
Office of Initial Patent Examination  
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Washington, DC 20231

LETTER

This is in response to receipt of the Updated Filing Receipt mailed 03/13/2002.

Please make the following correction to the receipt:

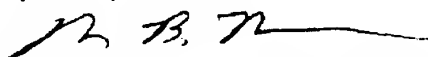
Please remove the sentence "THIS APPLN CLAIMS BENEFIT of 60/183,507 02/17/2000" from the "Domestic Priority data as claimed by applicant" section.

While this application is related to U.S. Provisional Application 60/183,507, a claim of priority has not been made.

This correction is marked in red on the attached updated filing receipt copy.

It is respectfully requested that a corrected filing receipt be promptly issued that properly reflects the Domestic Priority data.

Respectfully submitted,



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APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO.	DRAWINGS	TOT CLAIMS	IND CLAIMS
09/905,172	07/13/2001	1765	1290	004227 USA 02/ETCH/SILICO	9	34	5

CONFIRMATION NO. 2748

27774  
MAYER, FORTKORT & WILLIAMS, PC  
251 NORTH AVENUE WEST  
2ND FLOOR  
WESTFIELD, NJ 07090

UPDATED FILING RECEIPT



\*OC000000007631107\*

Date Mailed: 03/13/2002

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

**Applicant(s)**

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**Assignment For Published Patent Application**

Applied Materials, Inc.;

**Domestic Priority data as claimed by applicant**

~~THIS APPLN CLAIMS BENEFIT OF 60/183,507 DATED 02/17/2000~~

**Foreign Applications**

If Required, Foreign Filing License Granted 08/27/2001

Projected Publication Date: 06/20/2002

Non-Publication Request: No

Early Publication Request: No

**Title**

Etch pattern definition using a CVD organic layer as an anti-reflection coating and hardmask

**Preliminary Class**

438

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Title 35, United States Code, Section 184  
Title 37, Code of Federal Regulations, 5.11 & 5.15**

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